UNITED STATES DEPARTMENT OF COMMERCE United States Patent and Trademark Office Address: COMMISSIONER FOR PATENTS P.O. Box 1450 Alexandria, Virginia 22313-1450 www.uspto.gov

APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
10/519,998	01/05/2005	Shigeki Kambara	3273-0196PUS1	5132
	7590 04/06/200 ART KOLASCH & BI	EXAMINER		
PO BOX 747 FALLS CHURCH, VA 22040-0747			CHU, JOHN S Y	
			ART UNIT	PAPER NUMBER
			1752	
SHORTENED STATUTOR	Y PERIOD OF RESPONSE	NOTIFICATION DATE	DELIVERY MODE	
3 MOI	NTHS	04/06/2007	ELECTRONIC	

Please find below and/or attached an Office communication concerning this application or proceeding.

If NO period for reply is specified above, the maximum statutory period will apply and will expire 6 MONTHS from the mailing date of this communication.

Notice of this Office communication was sent electronically on the above-indicated "Notification Date" and has a shortened statutory period for reply of 3 MONTHS from 04/06/2007.

Notice of the Office communication was sent electronically on above-indicated "Notification Date" to the following e-mail address(es):

mailroom@bskb.com

	·		
	Application No.	Applicant(s)	
Office A.4' Occurrence	10/519,998	KAMBARA ET AL.	
Office Action Summary	Examiner	Art Unit	
·	John S. Chu	1752	_
The MAILING DATE of this communication appeared for Reply	ppears on the cover sheet wit	h the correspondence address	
A SHORTENED STATUTORY PERIOD FOR REP WHICHEVER IS LONGER, FROM THE MAILING - Extensions of time may be available under the provisions of 37 CFR 1 after SIX (6) MONTHS from the mailing date of this communication. - If NO period for reply is specified above, the maximum statutory perior - Failure to reply within the set or extended period for reply will, by statu Any reply received by the Office later than three months after the mail earned patent term adjustment. See 37 CFR 1.704(b).	DATE OF THIS COMMUNIC 1.136(a). In no event, however, may a re d will apply and will expire SIX (6) MONT ute, cause the application to become ABA	CATION. APPLY be timely filed FHS from the mailing date of this communication. ANDONED (35 U.S.C. § 133).	
Status			
1) Responsive to communication(s) filed on	·		
2a) This action is FINAL . 2b) ⊠ Th	is action is non-final.		
3) Since this application is in condition for allow	ance except for formal matte	ers, prosecution as to the merits is	
closed in accordance with the practice under	Ex parte Quayle, 1935 C.D.	11, 453 O.G. 213.	
Disposition of Claims			
4)⊠ Claim(s) <u>6-11</u> is/are pending in the application	n.		
4a) Of the above claim(s) is/are withdr	awn from consideration.	•	
5) Claim(s) is/are allowed.			
6)⊠ Claim(s) <u>6-11</u> is/are rejected.			
7) Claim(s) is/are objected to.			
8) Claim(s) are subject to restriction and	or election requirement.		
Application Papers			
9) The specification is objected to by the Examir	ner.		
10)☐ The drawing(s) filed on is/are: a)☐ ad	ccepted or b) objected to b	y the Examiner.	
Applicant may not request that any objection to the	e drawing(s) be held in abeyan	ce. See 37 CFR 1.85(a).	
Replacement drawing sheet(s) including the corre			
11) The oath or declaration is objected to by the I	Examiner. Note the attached	Office Action or form PTO-152.	
Priority under 35 U.S.C. § 119	•		
12)⊠ Acknowledgment is made of a claim for foreig	an priority under 35 U.S.C. §	119(a)-(d) or (f).	
a)⊠ All b)□ Some * c)□ None of:	•		
1. Certified copies of the priority docume	nts have been received.		
2. Certified copies of the priority docume	nts have been received in Ap	oplication No	
3. Copies of the certified copies of the pri	•	received in this National Stage	
application from the International Bure	, , , , , , , , , , , , , , , , , , , ,		
* See the attached detailed Office action for a lis	st of the certified copies not i	eceived.	
Attachment(s)	□	(070.446)	
Notice of References Cited (PTO-892) Notice of Draftsperson's Patent Drawing Review (PTO-948)		ummary (PTO-413))/Mail Date	
3) Information Disclosure Statement(s) (PTO/SB/08) Paper No(s)/Mail Date 1/9/07.		formal Patent Application	

Application/Control Number: 10/519,998 Page 2

Art Unit: 1752

DETAILED ACTION

This Office action is in response to the amendment filed December 11, 2006.

- 1. The rejection under 35 U.S.C. 102(e) as being clearly anticipated by SHIMA et al (2004/0048192 A1) or SOYANO et al (6,800,419 B2) is **withdrawn** in view of the amendment canceling claim 1-5.
- 2. Upon updating the search, new references were found which are used below:

Claim Rejections - 35 USC § 102

3. The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless -

- (b) the invention was patented or described in a printed publication in this or a foreign country or in public use or on sale in this country, more than one year prior to the date of application for patent in the United States.
- 4. Claims 6-11 are rejected under 35 U.S.C. 102(b) as being clearly anticipated by KODAMA et al (2002/0102491).

The claimed invention is now drawn to the following:

Application/Control Number: 10/519,998

Art Unit: 1752

6. (previously presented) A photoresist resin comprising at least a constitutional repeating unit A containing a group capable of partially leaving by the action of an acid to thereby become soluble in an alkali; and a constitutional repeating unit B containing an alicyclic skeleton having a polar group,

Page 3

wherein the resin

- (i.) has a weight-average molecular weight of 3000 to 15000 and
- (ii.) has a molecular weight distribution (Mw/Mn, wherein Mw is weight-average molecular weight and Mn is number-average molecular weight) of from 1.1 to 3.5 and
- (iii.) has a content of polymer fractions each having a molecular weight exceeding 40000 of 4 percent by weight or less of the total resin.

KODAMA et al disclose a positive photosensitive composition comprising a compound which generates a specified sulfonic acid and a resin capable of decomposing under the action of an acid to increase the solubility in an alkali-developer. Applicants are directed to <u>Table 5 on page 37 paragraph [462]</u> wherein resins (P11), (P15), (P19) and P(20) disclose resins made from monomers defined as b54, b55, b56, b1, b62, a5, b63, b64, b65 as seen on <u>pages 48 - 54</u> which meet the recited constitutional repeating units of A and B. The weight average molecular weight of the resins are (P11), (P15), (P19) and P(20), are 400, 11,000, 11,000 and 13,000, respectively and having a degree of dispersion (Mw/Mn) of 1.9, 1.8, 1.9 and 2.2, respectively.

These resins are exemplified in Examples 51, 52, 58-60 an d63-67 in Table 6 and 7 found on pages 73 and 74 and provide compositions which have high sensitivity, resolution and exposure margin.

Page 4

Art Unit: 1752

The claims are anticipated by the disclosure and no claims are allowed.

5. Any inquiry concerning this communication or earlier communications from the examiner should be directed to Examiner Chu whose telephone number is (571) 272-1329. The examiner can normally be reached on Monday - Friday from 9:30 am to 6:00 pm.

If attempts to reach the Examiner by telephone are unsuccessful, the Examiner's supervisor, Cynthia Kelly, can be reached on (571) 272-1526

The fax phone number for the USPTO is (571) 273-8300.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PMR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

John S. Chu

Primary Examiner, Group 1700

J.Chu March 30, 2007